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Information technology — Security techniques — Cryptographic techniques based on elliptic curves —

Part 1: General

Technologies de l'information — Techniques de sécurité — Techniques cryptographiques basées sur les courbes elliptiques —

Partie 1: Généralités

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Foreword

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The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular the different approval criteria needed for the different types of document should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

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For an explanation on the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the WTO principles in the Technical Barriers to Trade (TBT), see the following URL: Foreword — Supplementary information.

The committee responsible for this document is ISO/IEC JTC 1, *Information technology*, Subcommittee SC 27, *Security techniques*.

This third edition cancels and replaces the second edition (ISO/IEC 15946-1:2008 with ISO/IEC 15946-1/Cor 1:2009), which has been technically revised.

ISO/IEC 15946 consists of the following parts, under the general title *Information technology — Security techniques — Cryptographic techniques based on elliptic curves*:

— *Part 1: General*

— *Part 5: Elliptic curve generation*

Introduction

Cryptosystems based on elliptic curves defined over finite fields provide an interesting alternative to the RSA cryptosystem and to finite field discrete log based cryptosystems. The concept of an elliptic curve based public-key cryptosystem is simple.

— Every elliptic curve over a finite field is endowed with an addition operation "+" under which it forms a finite abelian group.

— The group law on elliptic curves extends in a natural way to a "discrete exponentiation" on the point group of the elliptic curve.

— Based on the discrete exponentiation on an elliptic curve, one can easily derive elliptic curve analogues of the well-known public-key schemes of the Diffie–Hellman and ElGamal type.

The security of such a public-key cryptosystem depends on the difficulty of determining discrete logarithms in the group of points of an elliptic curve. This problem is, with current knowledge, much harder for a given parameter size than the factorisation of integers or the computation of discrete logarithms in a finite field. Indeed, since Miller and Koblitz independently suggested the use of elliptic curves for public-key cryptographic systems in 1985, the elliptic curve discrete logarithm problem has only been shown to be solvable in certain specific, and easily recognisable, cases. There has been no substantial progress in finding a method for solving the elliptic curve discrete logarithm problem on arbitrary elliptic curves. Thus, it is possible for elliptic curve based public-key systems to use much shorter parameters than the RSA system or the classical discrete logarithm based systems that make use of the multiplicative group of some finite field. This yields significantly shorter digital signatures and system parameters and the integers to be handled by a cryptosystem are much smaller.

This part of ISO/IEC 15946 describes the mathematical background and general techniques necessary for implementing the elliptic curve cryptography mechanisms defined in ISO/IEC 15946-5, ISO/IEC 9796-3, ISO/IEC 11770-3, ISO/IEC 14888-3, ISO/IEC 18033-2 and other ISO/IEC standards.

It is the purpose of this part of ISO/IEC 15946 to meet the increasing interest in elliptic curve based public-key technology and to describe the components that are necessary to implement secure elliptic curve cryptosystems such as key-exchange, key-transport and digital signatures.

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